

UltraShield™:

THE FILM COATING SOLUTION FOR SAFELY STORING INNOVATIVE DRUG



State-of-the-art technology and design tailored to meet the highest demands for quality and performance



ROBUST TO ULTRA-LOW TEMPERATURE STORAGE

An efficient solution enabling the secure storage of drugs under ultra-low temperatures up to -80°C with a broad range of crimping parameters.



STRONG BARRIER TO AGGRESSIVE SOLVENTS

The film barrier limits drug-stopper interaction and forms an ultraprotection against aggressive excipients.



SUPERIOR CHEMICAL COMPATIBILITY

Our ultra-clean bromobutyl rubber substrate FM457 on which is applied a fluoropolymer film that covers the complete drug contact area and forms a barrier to obtain the lowest level of extractables and leachables.

HIGHEST QUALITY STANDARDS

UltraShield is manufactured according to Datwyler's FirstLine® concept ensuring the highest quality levels on the market.

| $UltraShield^{\text{TM}}$ |
|---------------------------|
| STOPPERS |









| Dimension | 13 mm | 20 mm | 13 mm | 20 mm | |
|-----------|--------------|--------------|----------|----------|--|
| Design | non-blowback | non-blowback | blowback | blowback | |
| Compound | FM457 | FM457 | FM457 | FM457 | |



UltraShield™

THE FILM COATED SOLUTION FOR SAFELY STORING INNOVATIVE DRUGS

FLUOROPOLYMER FILM

The fluoropolymer film is bonded to the plug during molding step to

drastically reduce interaction

between rubber and drug ingredients.



The non-treated landing zone of the flange ensures **optimum sealing properties** of bare rubber.



REDUCED FLANGE

The shape of the flange reduces the piercing thickness, improving penetration forces and fragmentation to accommodate the use of Closed

to accommodate the use of Closed System Transfer Devices (CSTD's).



The flange is covered with silicone cured with e-beam technology to

maintain optimal machinability while obtaining **best-in-**

class subvisible particle levels.

Additionally, this novel technology eliminates the need for any curing agent and therefore **contributes to the chemical performance**.



